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QUANTUM INDECISION IN LOGIC GATES(U) CORNELL UNIV

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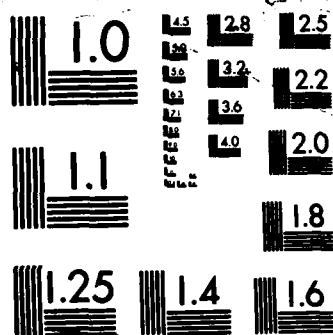
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20. Abstract

Working in the Drude approximation, the following relation is obtained for relative quantum uncertainty for current flow in micro devices,

$$\frac{\Delta J}{J} \geq \frac{1}{\bar{m}^*} \frac{\lambda_C}{2a} \frac{c}{v}$$

In this relation, λ_C is the Compton wavelength, \bar{m}^* is effective charge-carrier mass divided by electron mass, v is drift velocity, c is the speed of light and a is the channel length of the conduction domain of the device. With $v \leq c$ and at fixed \bar{m}^* , we see that for sufficiently small values of a , the reliability of a micro logic gate is impaired due to quantum uncertainty. Application to GaAs and InP, at present-day values of maximum charge-carrier drift velocities, reveals critical scale lengths $\approx 10^{-3} \mu\text{m}$.



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Introduction and Analysis

Logic gates in very large-scale integrated circuits typically employ standard variations of field-effect transistors (FET).^{1,2} In micro circuits, dimensions of such devices are of the order of 1 μm . Current technology seeks to further reduce the scale-length of micro-computer networks.³ Thus, the present work examines limitations imposed on the reliability of such logic gates due to quantum uncertainty which enters in the limit of small dimensions.^{4,5}

The uncertainty relation for momentum p and displacement x is given by

$$\Delta p \Delta x \geq \frac{\hbar}{2} \quad (1)$$

Uncertainty in momentum, say, is written for the mean-square displacement from the mean,

$$(\Delta p)^2 \equiv \langle (\langle p \rangle - p)^2 \rangle \quad (2)$$

With m^* denoting effective mass and v written for drift velocity we write

$$p = m^* v$$

Substitution into (1) gives

$$\Delta v \geq \frac{\hbar}{2m^* a} \quad (3)$$

where a is written for the channel length of the FET. Working in the Drude approximation,⁶ we write

$$J = env \quad (4)$$

for current density, where n is charge-carrier number density and e is electronic charge. The preceding relation permits (3) to be written

$$\Delta J \geq \frac{en\hbar}{2m^*a} \quad (5)$$

Dividing through by current density gives

$$\frac{\Delta J}{J} \geq \frac{1}{m^*} \frac{\lambda_C}{2a} \frac{c}{v} \quad (6)$$

where

$$\lambda_C = \frac{\hbar}{m_e c} = 3.86 \times 10^{-11} \text{ cm},$$

is the Compton wavelength, m_e is electron mass, m^* is the dimensionless effective mass,

$$m^* \approx \frac{m}{m_e},$$

and c is the speed of light.

The expression (6) indicates that current resolution is maintained providing the scale-length a is sufficiently large and drift velocity v is as large as feasible.

For n-type GaAs and InP, $m^* \approx 0.07$.^{7,8} Recently measured^{9,10} upper limits of v indicate $v \approx 4 \times 10^7$ cm/s. Substituting these values in (6) gives

$$\frac{\Delta J}{J} \geq \frac{2.14 \times 10^{-7}}{a} \quad (7)$$

Conclusions

Assuming that current resolution is lost at $\Delta J/J \geq 1/2$, with (7) we find that such will be the case for scale lengths $a \leq 4 \times 10^{-7}$ cm = 4×10^{-3} μ m. Repeating the calculation for p-type GaAs and InP ($\bar{m}^* \approx 0.5$), gives the limiting channel length. $a \approx 6 \times 10^{-4}$ μ m.

We have applied the quantum mechanical uncertainty relation for coordinate and momentum to obtain a relation for quantum uncertainty of current flow in micro devices. It is argued that such uncertainty, when present, would destroy the reliability of input-output relations in micro-logic gates, thereby placing a lower bound on the dimensions of such devices.

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